

EAST Search History

| Ref # | Hits | Search Query | DBs | Default Operator | Plurals | Time Stamp |
|-------|--------|---|--|------------------|---------|---------------------|
| L1 | 27 | ((TOSHIYUKI) near2 (KAWAGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2009/07/08 09:08 |
| L2 | 97 | ((HIRONAO) near2 (FUJIKI)).INV. | US-PGPUB; USPAT | OR | ON | 2009/07/08 09:08 |
| L3 | 22 | ((ATSUSHI) near2 (TANIGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2009/07/08 09:12 |
| L4 | 8 | ((TAKASHI) near2 (GONDA)).INV. | US-PGPUB; USPAT | OR | ON | 2009/07/08 09:12 |
| L5 | 13 | ((KAZUTOKI) near2 (TAHARA)).INV. | US-PGPUB; USPAT | OR | ON | 2009/07/08 09:13 |
| L6 | 3 | ("6921573").PN. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 09:15 |
| L7 | 3975 | 428/411.1.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:14 |
| L8 | 388 | L7 and (electromagnetic or emf or emi or rfi) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:14 |
| L9 | 59 | L8 and resistivity | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:14 |
| L10 | 50 | electromagnetic near3 noise near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:15 |
| L11 | 1303 | electromagnetic near3 noise near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:15 |
| L12 | 300839 | (vapor near3 deposition) or vapor-deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:15 |
| L13 | 68 | (L10 or L11) and L12 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/07/08 12:15 |
| S1 | 44 | electromagnetic near3 noise near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:20 |

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|-----|--------|---|---|----|----|------------------|
| S2 | 1053 | electromagnetic near3 noise near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:33 |
| S3 | 238521 | (vapor near3 deposition) or vapor-deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/06/11 12:00 |
| S4 | 50 | S2 and S3 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:25 |
| S5 | 33 | S4 and (polymer or resin or rubber) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:33 |
| S6 | 16 | electromagnetic near3 radiation near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:32 |
| S7 | 247725 | (vapor near3 deposition) or vapor-deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:32 |
| S8 | 2 | S7 and S6 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:32 |
| S9 | 3077 | electromagnetic near3 radiation near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:38 |
| S10 | 230 | S7 and S9 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:33 |
| S11 | 192 | S10 and (polymer or resin or rubber) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/11 16:33 |
| S12 | 44 | electromagnetic near3 noise near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:20 |
| S13 | 1093 | electromagnetic near3 noise near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:38 |
| S14 | 16 | electromagnetic near3 radiation near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:38 |

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| S15 | 3077 | electromagnetic near3 radiation near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:38 |
| S16 | 4125 | S12 or S13 or S14 or S15 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:38 |
| S17 | 247725 | (vapor near3 deposition) or vapor-deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:39 |
| S18 | 284 | S16 and S17 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:39 |
| S19 | 14 | S18 and (flame near3 retardant) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:54 |
| S20 | 77 | S16 and (flame near3 retardant) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 08:55 |
| S21 | 2116 | (halogen near3 free) same (flame near3 retardant) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 09:11 |
| S23 | 18 | S21 same benefit | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 09:11 |
| S24 | 1167 | (halogen near3 non) same (flame near3 retardant) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 09:11 |
| S25 | 2 | S24 same benefit | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 10:25 |
| S26 | 38 | "5864088" or "6448491" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/17 15:09 |
| S27 | 10 | S26 and deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 12:54 |
| S30 | 241 | 174/350.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 12:53 |

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|-----|-------|--|--|----|----|---------------------|
| S31 | 20 | S30 and deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:26 |
| S33 | 3 | 174/35 near3 ms | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:16 |
| S34 | 130 | 174/391.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:25 |
| S35 | 21 | S34 and deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/12 13:26 |
| S36 | 25 | ((TOSHIYUKI) near2 (KAWAGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:46 |
| S37 | 94 | ((HIRONAO) near2 (FUJIKI)).INV. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:46 |
| S38 | 18 | ((ATSUSHI) near2 (TANIGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:46 |
| S39 | 8 | ((TAKASHI) near2 (GONDA)).INV. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:46 |
| S40 | 12 | ((KAZUTOKI) near2 (TAHARA)).INV. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:47 |
| S41 | 151 | S36 or S37 or S38 or S39 or S40 | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:48 |
| S42 | 8 | S41 and (electromagnetic or noise).clm. | US-PGPUB; USPAT | OR | ON | 2007/10/12 13:49 |
| S43 | 12 | opposing near3 target near3 magnetron near3 sputtering | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/17 15:12 |
| S44 | 106 | opposing near3 target near3 sputtering | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/17 15:45 |
| S45 | 18 | opposing near3 target near3 magnetron | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/17 15:45 |
| S46 | 6 | S45 not S43 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/17 15:45 |
| S47 | 77812 | deposition and (thickness same nm) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:10 |

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|-----|-------|---|--|----|----|---------------------|
| S48 | 30281 | deposition same (thickness same nm) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:11 |
| S49 | 25169 | sputtering same (thickness same nm) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:11 |
| S50 | 2520 | (magnetron near3 sputtering) same (thickness same nm) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:21 |
| S51 | 2 | (opposing near3 magnetron near3 sputtering) same (thickness same nm) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:12 |
| S52 | 2164 | S50 and metal | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:12 |
| S53 | 1204 | S52 and (electromagnetic or EMF or rf) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:14 |
| S54 | 803 | S53 not (recording near3 medium) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:15 |
| S55 | 4752 | electromagnetic near3 (noise or wave) near3 (suppressor or absorb or absorber or suppress) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:21 |
| S56 | 16 | (magnetron near3 sputtering) and S55 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2007/10/18 12:21 |
| S57 | 8 | ("4784739" "5864088" "5990417" "6104530").PN. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/15 14:21 |
| S58 | 2 | "20040219328" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/15 14:22 |
| S59 | 27 | ((TOSHI YUKI) near2 (KAWAGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/05/15 14:52 |
| S60 | 94 | ((HIRONAO) near2 (FUJIKI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/05/15 14:53 |
| S61 | 20 | ((ATSUSHI) near2 (TANIGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/05/15 14:53 |
| S62 | 8 | ((TAKASHI) near2 (GONDA)).INV. | US-PGPUB; USPAT | OR | ON | 2008/05/15 14:54 |

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| S63 | 13 | ((KAZUTOKI) near2 (TAHARA)).INV. | US-PGPUB; USPAT | OR | ON | 2008/05/15 14:54 |
| S64 | 2301 | (halogen near3 free) same (flame near3 retardant) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:09 |
| S65 | 19 | S64 same benefit | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:09 |
| S66 | 3 | S65 and (nm or nanometer or (fine near3 particle)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:09 |
| S67 | 45 | electromagnetic near3 noise near3 suppressor | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:10 |
| S68 | 9 | S67 and (nm or nanometer or (fine near3 particle)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:10 |
| S69 | 3215 | electromagnetic near3 radiation near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:14 |
| S70 | 498 | S69 and (nm or nanometer or (fine near3 particle)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:14 |
| S71 | 352017 | (vapor near3 deposition) or vapor-deposition or cvd or pvd | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:21 |
| S72 | 134 | S70 and S71 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:21 |
| S73 | 2 | "6869683" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:55 |
| S74 | 2 | "20030044623" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 10:56 |
| S75 | 11541 | 204/192.1-192.38.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:21 |

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|-----|--------|---|--|----|----|---------------------|
| S76 | 3812 | S71 and S75 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:22 |
| S77 | 2 | S70 and S76 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:22 |
| S78 | 1281 | S76 and (nm or nanometer or (fine near3 particle)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:24 |
| S80 | 188157 | (embed or embedding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:29 |
| S81 | 8634 | S71 and S80 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:29 |
| S82 | 1492 | S71 same S80 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 13:30 |
| S83 | 500 | S82 not (semiconductor near3 device) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/19 14:07 |
| S84 | 10519 | lattice and magnetic and (binder or polymer) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 14:10 |
| S85 | 2174 | S84 and ((vapor near3 deposition) or pvd) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 14:10 |
| S86 | 3335 | lattice same ((vapor near3 deposition) or pvd) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 14:11 |
| S87 | 167 | S84 and S86 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 14:11 |
| S88 | 3048 | ((physical near3 vapor near3 deposition) or pvd) and ((electron near3 volt) or ev) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 15:27 |
| S89 | 832 | S88 and magnetic | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 15:27 |

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|------|--------|---|--|----|----|---------------------|
| S90 | 267 | S89 and lattice | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/05/20 15:28 |
| S91 | 2 | "6869683" | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/11/04 16:37 |
| S92 | 27 | ((TOSHIYUKI) near2 (KAWAGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:00 |
| S93 | 96 | ((HIRONAO) near2 (FUJIKI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:00 |
| S94 | 20 | ((ATSUSHI) near2 (TANIGUCHI)).INV. | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:01 |
| S95 | 8 | ((TAKASHI) near2 (GONDA)).INV. | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:02 |
| S96 | 13 | ((KAZUTOKI) near2 (TAHARA)).INV. | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:02 |
| S97 | 9 | "5990417" | US-PGPUB; USPAT | OR | ON | 2008/11/04 17:03 |
| S98 | 1211 | electromagnetic near3 noise near3 (shield or shielding) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/11/04 17:10 |
| S99 | 281865 | (vapor near3 deposition) or vapor-deposition | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/11/04 17:10 |
| S100 | 60 | S98 and S99 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/11/04 17:10 |
| S101 | 42 | S100 and (polymer or resin or rubber) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2008/11/04 17:10 |
| S102 | 5445 | electromagnetic near3 (noise or wave) near3 (suppressor or absorb or absorber or suppress) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:27 |
| S103 | 21 | (magnetron near3 sputtering) and S102 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:27 |
| S104 | 61637 | (noise or wave) near3 (suppressor or absorb or absorber or suppress) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:32 |
| S105 | 342608 | pvd or (vapor near3 deposit\$5) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:32 |

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|------|--------|---|--|----|----|---------------------|
| S106 | 58 | S104 same S105 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:32 |
| S107 | 16 | S106 and particle | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 15:37 |
| S108 | 22 | ("20040108486" "20040157085" "20040219328" "20060038630" "20060083948" "20070077369" "4784739" "5864088" "5990417" "6104530" "6869683" "7160636"). PN. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 16:04 |
| S109 | 1352 | S104 and S105 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 16:33 |
| S110 | 112045 | S109 and gigahertz or ghz | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 16:33 |
| S111 | 269 | S109 and (gigahertz or ghz) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 16:33 |
| S112 | 69 | S111 and resistivity | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/11 16:45 |
| S113 | 61657 | (noise or wave) near3 (suppressor or absorb or absorber or suppress) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/12 14:25 |
| S114 | 342791 | pvd or (vapor near3 deposit\$5) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/12 14:25 |
| S115 | 1353 | S113 and S114 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/12 14:25 |
| S116 | 99 | S115 and eV | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/12 14:25 |
| S117 | 8297 | 204/192.1-192.2.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 08:59 |

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|------|--------|---|--|----|----|---------------------|
| S118 | 623 | S117 and (ev or (electron near3 volt)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 09:00 |
| S119 | 339 | S118 and (resistance or resistivity) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 09:00 |
| S120 | 147 | S118 and resistivity | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 09:02 |
| S121 | 142895 | anisotropic | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:06 |
| S122 | 15366 | S121 and resistivity | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:07 |
| S123 | 9206 | S122 and crystal\$4 | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:07 |
| S124 | 831 | S123 and (ev or (electron near3 volt)) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:08 |
| S125 | 681 | S124 and (nm or nanometer) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:09 |
| S126 | 189 | S125 and (electromagnetic or emf or emi or rfi) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/13 11:13 |
| S127 | 20 | opposing near3 target near3 magnetron | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/14 11:26 |
| S129 | 3937 | 428/411.1.ccls. | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/14 13:19 |
| S130 | 381 | S129 and (electromagnetic or emf or emi or rfi) | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/14 13:20 |
| S131 | 59 | S130 and resistivity | US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT | OR | ON | 2009/05/14 14:10 |

7/ 8/ 2009 2:38:25 PM

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